

Fig. 1: Evolution of RHEED pattern along the $\langle 110 \rangle$ zone axis for the 4X period $\text{Sc}_x\text{Al}_{1-x}\text{N}/\text{GaN}$ multilayer heterostructure. All diffraction images suggest the layers are epitaxial and single-crystalline. The GaN layers recover their 1x1 streaks and maintain their hexagonal crystal structure.

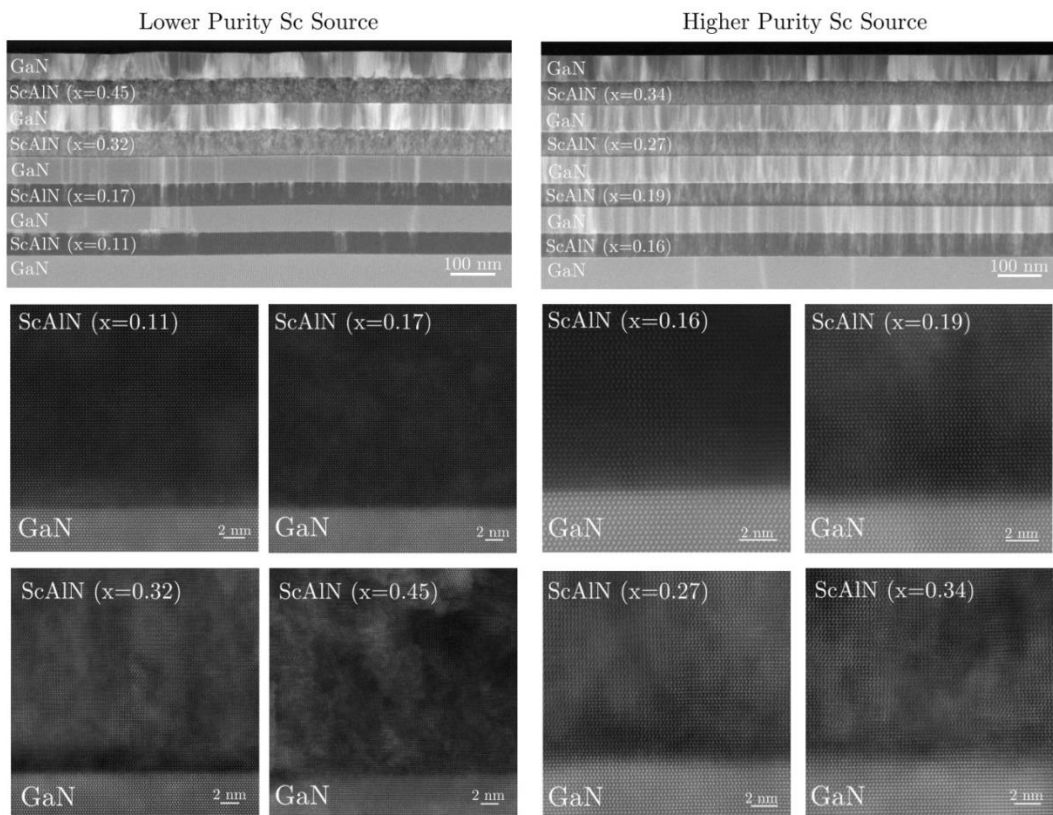


Fig. 3: STEM images of the heterostructures grown with lower purity Sc source (left) and higher purity Sc source (right). Increased defect densities are seen in the high Sc composition $\text{Sc}_x\text{Al}_{1-x}\text{N}$ layers for both samples grown with lower and higher purity Sc sources. Atomic resolution images near the interfaces are acquired with a shorter camera length for atomic number (Z)-dominant contrast between $\text{Sc}_x\text{Al}_{1-x}\text{N}$ layers and GaN. GaN is observed to be wurtzite in all layers.